

SF-100 XTREME



Full Featured & Versatile Maskless Microlithography

Everything You Need to Pattern Features as Small as 1 Micron

If you need a complete maskless lithography system to do advanced research or photomask fabrication, look no further than the **SF-100 XTREME**. This system comes with everything you need to do high precision, quick turnaround maskless photoresist patterning. Through advanced system design, important process variables such as exposure wavelength, pixel size and exposure energy level are easily chosen by the user so the system can work within your existing process and be compatible with your existing materials.

The SF-100 XTREME Comes Complete with Many Standard Features

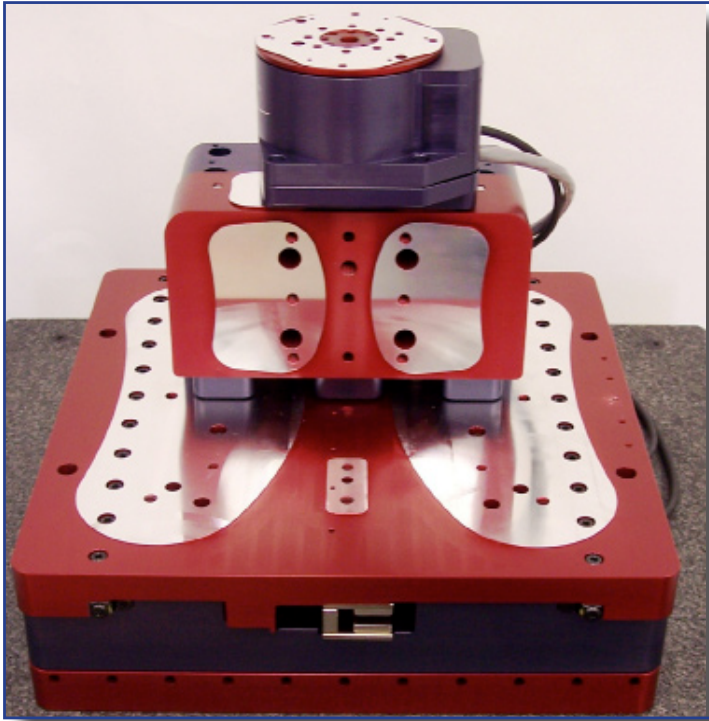
- Mercury arc lamp provides standard wavelength energies for compatibility with most commercial photoresists, polyimides, and SU8. Mercury arc lamp assemblies are included with each system purchase at no cost for the first 2 years of operation. After 2 years, the cost of the lamps are typically less than \$2000 USD per year, assuming normal system operation.
- Changing wavelengths is a snap using our 6 position filter wheel, which is easily controlled through the software.
- Our patented, field proven Smart Filter Technology is the heart of our system, using a TI DLP® chip to generate patterns.
- Combining our high resolution CCD camera with National Instruments' Vision Development® software package, functions such as autofocus, character recognition, and level to level alignment are easily provided and tailored to your specific needs.
- Use our fully integrated XYZ theta stage to stitch together images to make large die or multiple copies of the same die on a single substrate.
- Fully integrated vibration isolation table ensures repeatable and consistent process results, down to 1 micron in size.



- All stages come with XYZ and theta as standard. Theta provides full 360 degree travel and Z travel is a minimum of 25mm, allowing you to run different substrates easily. X and Y stage sizes start at 100mm travel, allowing users who pattern small substrates to minimize their capital investment and avoid purchasing a stage that is too large for their needs.
- All 3 High Resolution reduction lenses are included, so changing pixel size is a snap.
- Labwindows™ based software provides an open platform for software customization and integration with other systems.
- Rapid prototyping of new designs and ideas without the need for costly photomasks.
- IMP's legendary customer service, engineering, and support services ensure your success.
- Complete 1 year warranty, including customer training at system witness and at the customer site are included with each system purchase.

SF-100
XTREME

Linear Motor Stage Technology Exceeds the Requirements of Your Process

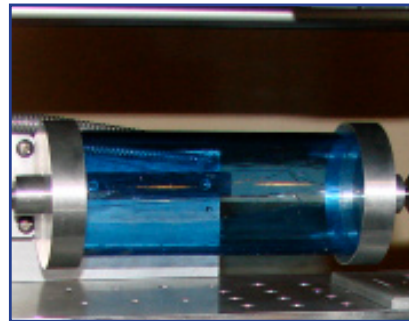


Beyond our proprietary optical design, the stage assembly is the most critical sub-assembly on the **SF-100 XTREME**. Stitching accuracy is critical to obtain acceptable process results and high performance of your devices. Our linear motor stage assembly offers high precision, robust design, and repeatability that will ensure very tight stitching accuracy day in and day out. Typical results from this stage include:

	<i>X Axis</i>	<i>Y Axis</i>	<i>Z Axis</i>	<i>R Axis</i>
<i>Travel</i>	150mm	150mm	25mm	360 degrees
<i>Resolution</i>	4.88nm	4.88nm	4.88nm	0.03 arc-sec
<i>Accuracy</i>	+/- 200nm	+/- 200nm	+/- 200nm	N/A
<i>Repeatability</i>	+/-50nm	+/-50nm	+/-75nm	+/-1 arc-sec

Customize Your SF-100 XTREME with These Available Options

- Need to pattern cylinders? Our rotational substrate stage is your answer. Pattern cylinders whose diameters range from a millimeter to several inches. This capability is fully integrated into your **SF-100 XTREME**, so even complicated patterning processes are obtained with one button ease of use.
- IMP's Microfluidic Research Option for the **SF-100 XTREME** provides temperature control at the substrate, including temperature cycling. Use of this option allows you to increase the use of your system from a standalone microlithography system to a system that can do patterning and analysis on microfluidics devices.
- Ensure your success over the long term through the use of our various maintenance agreements and extended product warranties.
- Custom hardware and software engineering programs can be undertaken to provide you with the exact system capabilities and configuration your system needs to support your unique, one of a kind research.



Contact your local customer service representative for more information on the **SF-100 XTREME**.

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